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GB 2394036 A EP 1418629 A2
EP 1357333 A2 US 20030035299 A1

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UK CL (Edition W) F4R
INT CL⁷ B60Q, F21H, F21S, F21V
Other: WPI, EPDOC, PAJ;

(54) Abstract Title: Headlamp for vehicles

(57) A vehicle headlight structure 10 includes a light distribution pattern having a horizontal cutoff line (fig. 3, CL1) formed by a reflecting optical system 18. The structure includes a first light source 16, a semiconductor light emitting unit or light emitting diode (LED), in which a rectangular light emitting chip is covered with a mould lens 24, and a reflector 18 for reflecting the light from the light source 16 toward the front of the lighting unit. The light emitting chip faces in a horizontal direction with one side of the chip set horizontally. The horizontal cut-off line is formed by selectively utilising the light emitted from the light source 16 and reflected by the reflector in the reflecting region (fig. 3, Za) positioned in front of the light emitting chip. Also disclosed is a headlamp structure utilising the above system in conjunction with a second similar system where the second light emitting chip is inclined downwards to form an oblique cut off line. There is also a further disclosure of a similar system where the light sources are not limited to semiconductor light emitting units or light emitting diodes.

FIG. 2

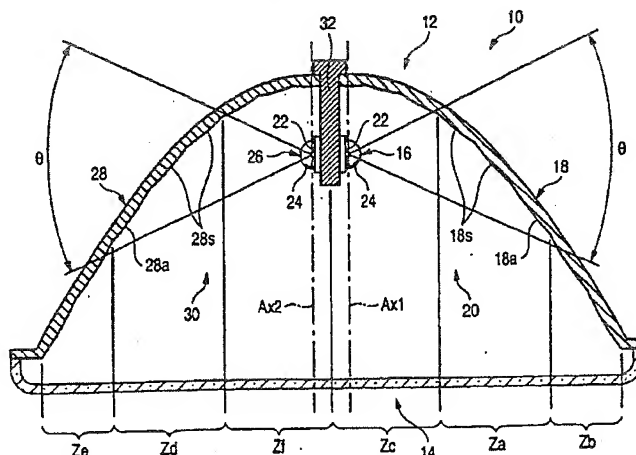


FIG. 4 (a)

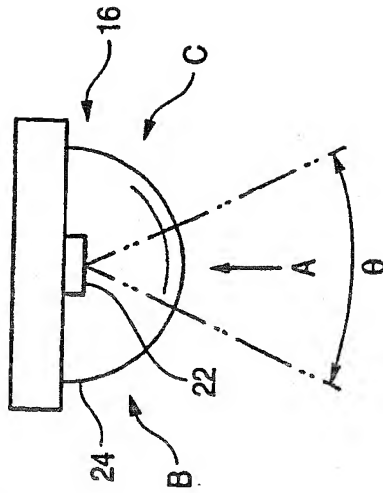
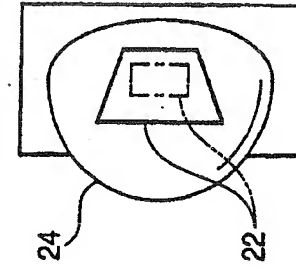
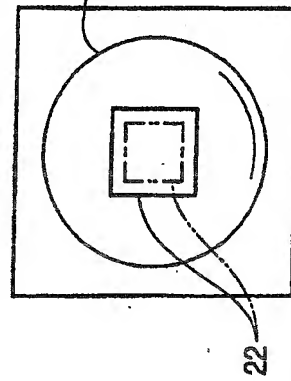


FIG. 4 (b)

VIEW FROM C DIRECTION



VIEW FROM A DIRECTION



VIEW FROM B DIRECTION

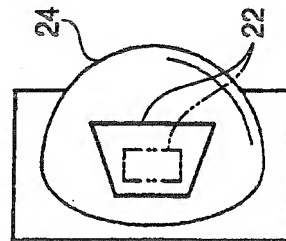
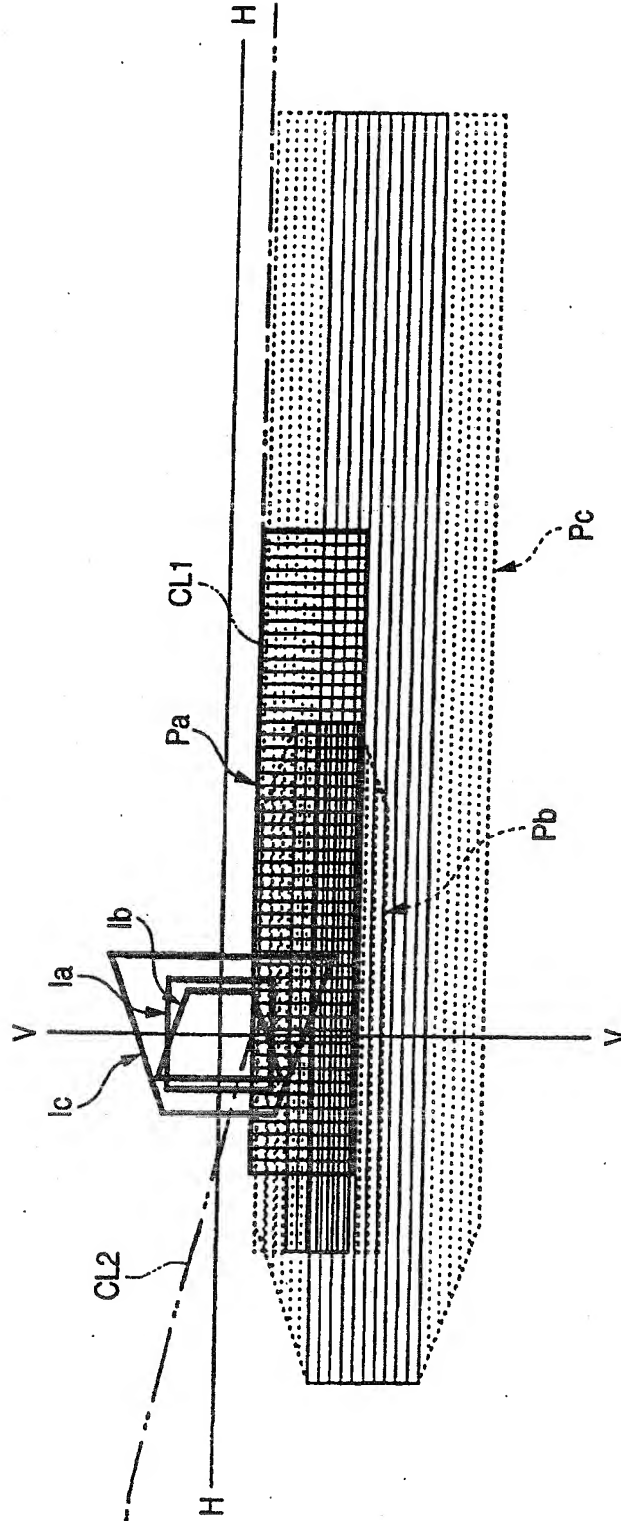
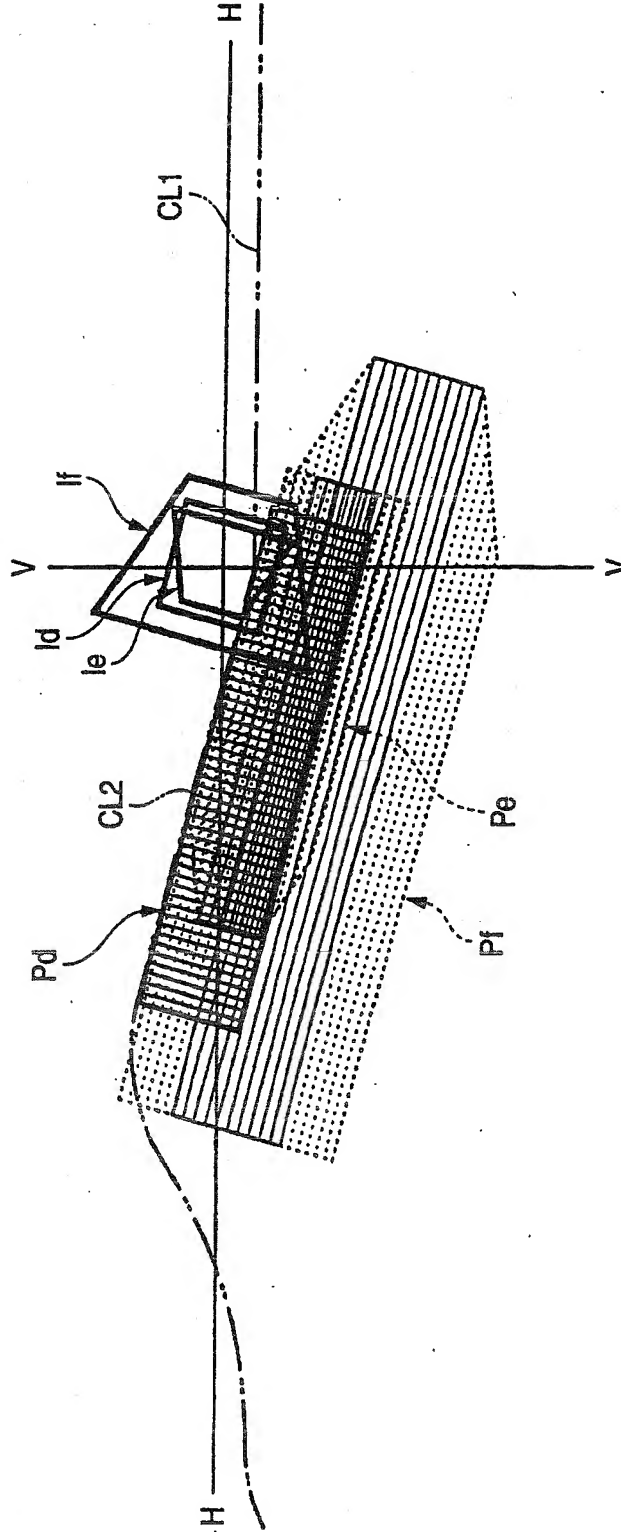


FIG. 5



NO. 23

FIG. 6



33 42 33

HEADLAMP FOR VEHICLE

5 The present invention relates to a vehicle headlamp that forms a light distribution pattern having a horizontal cutoff line by a reflecting optical system comprising a light source including a semiconductor light emitting unit.

10 In a related art marker lamp for a vehicle, such as a tail lamp, a light emitting diode has often been used as a light source. For example, JP-A-2001-332104, discloses a marker lamp for a vehicle in which a plurality of lighting units using light emitting diodes as light sources are arranged.

15

In recent years, the luminance of the related art light emitting diode has been enhanced. Therefore, there is a growing tendency to employ the light emitting diode as the light source of a headlamp for a vehicle.

20

However, a large number of light emitting diodes have such a structure that an almost rectangular light emitting chip is covered with an almost hemispherical mold lens as described in the above-referenced JP-A-2001-332104. When
25 the light emitting diode is employed as the light source of the vehicle headlamp, various related art problems occur.

For example, but not by way of limitation, in the related art vehicle headlamp, it is necessary to employ a
30 structure in which a light distribution pattern having a horizontal cutoff line can be formed so as not to produce glare to a driver in an oncoming car. In that case, the light distribution pattern is formed as the aggregate of the inverted image of a light source in a headlamp for a
35 vehicle having a reflecting optical system that reflects a light emitted from the light source toward the front part of a lighting unit by a reflector.

At this time, the image of a light emitting chip is greatly deformed, depending on the position of a light incidence on the reflector by the convex lens action of a mold lens. Therefore, a horizontal cutoff line cannot be
5 formed clearly. For this reason, there is a related art problem in that the generation of glare cannot be suppressed effectively.

It is an object of the invention to provide a vehicle
10 headlamp capable of effectively suppressing generation of glare by providing a light distribution pattern having a horizontal cutoff line is formed by a reflecting optical system that includes a light source having a semiconductor light emitting unit.

15

To achieve at least the foregoing object, the present invention provides a reflecting optical system that includes a vehicle headlamp constituted to form a light distribution pattern having a horizontal cutoff line by a
20 first reflecting optical system comprising a first light source including a semiconductor light emitting unit in which an almost rectangular light emitting chip is covered with an almost hemispherical mold lens and a first reflector for reflecting a light emitted from the first
25 light source toward a front part of a lighting unit. In the foregoing system, the first light source is provided such that the light emitting chip is turned in an almost horizontal direction with one side of the light emitting chip set almost horizontally, and the first reflecting
30 optical system forms the horizontal cutoff line by selectively utilizing a light emitted from the first light source and reflected by the first reflector which is reflected in a reflecting region positioned in an almost front direction of the light emitting chip.

35

The "light distribution pattern having a horizontal cutoff line" may be a so-called light distribution pattern

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(57) A vehicle headlight structure 10 includes a light distribution pattern having a horizontal cutoff line (fig. 3, CL1) formed by a reflecting optical system 18. The structure includes a first light source 16, a semiconductor light emitting unit or light emitting diode (LED), in which a rectangular light emitting chip is covered with a mould lens 24, and a reflector 18 for reflecting the light from the light source 16 toward the front of the lighting unit. The light emitting chip faces in a horizontal direction with one side of the chip set horizontally. The horizontal cut-off line is formed by selectively utilising the light emitted from the light source 16 and reflected by the reflector in the reflecting region (fig. 3, Za) positioned in front of the light emitting chip. Also disclosed is a headlamp structure utilising the above system in conjunction with a second similar system where the second light emitting chip is inclined downwards to form an oblique cut off line. There is also a further disclosure of a similar system where the light sources are not limited to semiconductor light emitting units or light emitting diodes.

FIG. 2

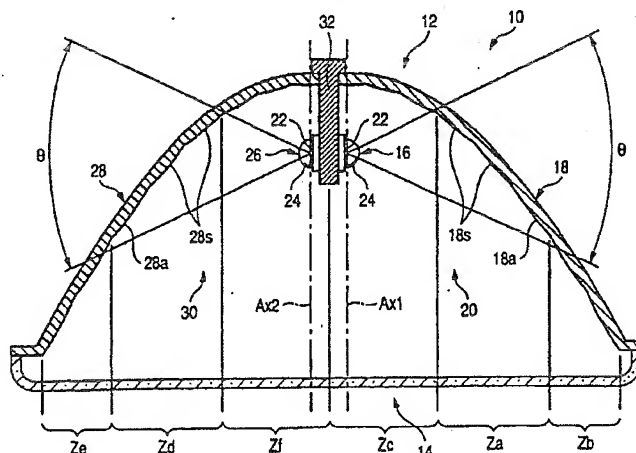


Fig. 5 is a view showing the image of the first light source and a horizontal cutoff line forming pattern formed on the virtual vertical screen by a light reflected from a reflecting region positioned in the almost front direction of the light emitting chip in a first reflector of the vehicle headlamp, and,

Fig. 6 is a view showing the image of a second light source and an oblique cutoff line forming pattern formed on the virtual vertical screen by a light reflected from a reflecting region positioned in the almost front direction of the light emitting chip in a second reflector of the vehicle headlamp.

Fig. 1 is a front view showing a headlamp 10 for a vehicle according to an exemplary, non-limiting embodiment of the present invention, and Fig. 2 is a sectional view taken along a line II — II in Fig. 1.

The headlamp 10 for a vehicle is a lighting unit that forms a light distribution pattern for a low beam, and includes a reflector unit 12 and a transparent cover 14 attached to an opening portion on the front end of the reflector unit 12.

The reflector unit 12 includes a first reflecting optical system 20 having a first light source 16 and a first reflector₁ 18, and a second reflecting optical system 30 having a second light source 26 and a second reflector 28. Both of the first and second light sources 16 and 26 include light emitting diodes formed by covering rectangular light emitting chips 22 with hemispherical mold lenses 24, and are supported by a common holder 32. Moreover, the first and second reflectors 18 and 28 are formed integrally.

The first light source 16 is provided such that the light emitting chip 22 is turned in a left and horizontal direction with one side of the light emitting chip 22 set horizontally. On the other hand, the second light source 26 is provided in such a manner that the light emitting chip 22 is turned in a downward inclined direction at about 15 degrees to a right and horizontal direction with one side of the light emitting chip 22 set horizontally.

10 A reflecting surface 18a of the first reflector 18 is provided with a plurality of reflecting units 18s by setting, as a central axis, an optical axis Ax1 extended in a longitudinal direction to pass through the center position of the surface of the light emitting chip 22 in
15 the first light source 16 and using, as a reference plane, a paraboloid of revolution setting the center position of the surface of the light emitting chip 22 to be a focal point.

20 On the other hand, a reflecting surface 28a of the second reflector 28 is provided with a plurality of reflecting units 28s by setting, as a central axis, an optical axis Ax2 extended in a longitudinal direction to pass through the center position of the surface of the
25 light emitting chip 22 in the second light source 26 and using, as a reference plane, a paraboloid of revolution setting the center position of the surface of the light emitting chip 22 to be a focal point.

30 Fig. 3 is a perspective view showing a light distribution pattern PL for a low beam formed on a virtual vertical screen 25m in front of a lighting unit with a light irradiated forward from the headlamp 10.

35 The light distribution pattern PL for a low beam is a left light distribution pattern having horizontal and oblique cutoff lines CL1 and CL2 on an upper edge thereof.

The light distribution pattern is formed as a synthetic light distribution pattern obtained by two light distribution patterns formed by means of the first and second reflecting optical systems 20 and 30.

5

In the low beam light distribution pattern PL, the position of an elbow point E at an intersection of both cutoff lines CL1 and CL2 is set downward by approximately 0.5 to 0.6 degree of H-V as a vanishing point in the front
10 direction of the lighting unit, and a hot zone HZ as a region having a high luminous intensity is formed in a slightly leftward position with respect to the elbow point E.

15 In the light distribution pattern PL for a low beam, a horizontal cutoff line forming pattern Pa for forming the horizontal cutoff line CL1 is formed by a light reflected from a reflecting region Za positioned substantially in front of the light emitting chip 22 of the first light
20 source 16 in the reflecting surface 18a of the first reflector 18. This is shown more specifically in FIG. 2.

Horizontal cutoff line reinforcing patterns Pb and Pc for reinforcing the horizontal cutoff line forming pattern
25 Pa are formed by a light reflected from a reflecting region Zb positioned on an outer peripheral side of the reflecting region Za, and a light reflected from a reflecting region Zc positioned on an inner peripheral side thereof.

30 In the light distribution pattern PL for a low beam, an oblique cutoff line forming pattern Pd for forming the oblique cutoff line CL2 is formed by a light reflected from a reflecting region Zd positioned substantially in front of the light emitting chip 22 of the second light source 26 in
35 the reflecting plane 28a of the second reflector 28. Oblique cutoff line reinforcing patterns Pe and Pf for reinforcing the oblique cutoff line forming pattern Pd are

formed by a light reflected from a reflecting region Ze positioned on an outer peripheral side of the reflecting region Zd and a light reflected from a reflecting region Zf positioned on an inner peripheral side thereof.

5

Portions other than the oblique cutoff line forming patterns Pa and Pd and the oblique cutoff line reinforcing patterns Pb, Pc, Pe and Pf in the light distribution pattern PL for a low beam are formed by lights reflected from regions other than the reflecting regions Za, Zb and Zc on the reflecting surface 18a and regions other than the reflecting regions Zd, Ze and Zt on the reflecting surface 28a.

15

As described above, in the first and second reflecting optical systems 20 and 30, the horizontal cutoff line CL1 and the oblique cutoff line OL2 are formed by selectively utilizing the lights reflected from the first and second reflectors 18 and 28, which are reflected in the reflecting regions Za and Zd positioned substantially in front of the light emitting chips 22 of the first and second light sources 16 and 26. The foregoing occurs for at least the following reasons.

25

As shown in Fig. 4(a), when the light emitting diode constituting the first light source 16 is observed from the outside, the light emitting chip 22 is seen enlargingly by the convex lens action of the mold lens 24. At this time, the shape of the light emitting chip 22 appears distorted greatly depending on a direction of observation.

30

More specifically, in Fig. 4 (b), the light emitting chip 22 originally having a shape shown by a two-dotted chain line appears enlarged as shown by a solid line. In other words, when the first light source 16 is observed in a front direction, the light emitting chip 22 is seen with

35

an almost rectangular shape, maintained as seen in a direction of an arrow A in Figs. 4(a)-(b)

When the observation is carried out in a direction
5 substantially shifted from the front direction, the light
emitting chip 22 appears deformed in a substantially
trapezoidal shape, as seen in a direction of an arrow B or
arrow C in Figs. 4(a)-(b). In that case, the shape of the
light emitting chip 22 can be regarded to be almost
10 rectangular within a range of an angle θ around the front
direction of the light emitting chip 22. The angle θ has a
value of approximately 50 degrees.

As shown in Fig. 2, a region positioned within a range
15 of the angle θ on the reflecting surface 18a of the first
reflector 18 is set to be the reflecting region Za.
Furthermore, a region positioned within a range of the
angle θ on the reflecting surface 28a of the second
reflector 28 is set as the reflecting region Zd.

20 The image of the first light source 16 is formed as an
inverted image on the virtual vertical screen by the light
reflected from the first reflector 18. At this time, if the
reflecting surface 18a is a paraboloid of revolution,
25 images Ia, Ib and Ic of the first light source 16 formed by
the lights reflected from the reflecting regions Za, Zb and
Zc have shapes obtained by rotating, by 180 degrees, the
shape of the light emitting chip 22, which is shown in the
solid line of Fig. 4 (b). This effect is shown in Fig. 5.

30 In other words, the image Ia formed by the light
reflected from the reflecting region Za becomes almost
rectangular, and the images Ib and Ic formed by the lights
reflected from the reflecting regions Zb and Zc become
35 almost trapezoidal. In that case, the image Ib formed by
the light reflected from the reflecting region Zb is
smaller than the image Ic formed by the light reflected

from the reflecting region Zo, depending on a difference in a distance from the light emitting chip 22 to each of the reflecting regions Za, Zb and Zc.

5 The images Ia, Ib and Ic of the first light source 16 are actually formed as the horizontal cutoff line forming pattern Pa and the horizontal cutoff line reinforcing patterns Pb and Pc by the deflecting and diffusing functions of the reflecting units 18s formed on the
10 reflecting surface 18a of the first reflector 18.

In that case, the horizontal cutoff line forming pattern Pa is formed by downwardly deflecting the image Ia of the reflecting region Za to a position in which an upper
15 edge thereof is level with the horizontal cutoff line CL1, and carrying out deflection and diffusion in a horizontal direction. At this time, the image Ia takes an almost rectangular shape and the upper edge thereof is extended in an almost horizontal direction. Also in the horizontal
20 cutoff line forming pattern Pa, the upper edge has a high contrast ratio. Consequently, it is possible to obtain the clear horizontal cutoff line CL1.

Moreover, the horizontal cutoff line reinforcing
25 patterns Pb and Pc are formed by downward deflecting the images Ib and Ic of the reflecting regions Zb and Zc to a position in which they are hidden under the horizontal cutoff line CL1, and carrying out deflection and diffusion in a horizontal direction. At this time, the images Ib and
30 Ic take substantially trapezoidal shapes and have upper edges that extend obliquely. In the horizontal cutoff line reinforcing patterns Pb and Pc, the upper edges do not have high contrast ratios. Since the patterns Pb and Pc are hidden under the horizontal cutoff line CL1, however, glare
35 generation can be prevented. By the horizontal cutoff line reinforcing patterns Pb and Pc, it is possible to maintain

a brightness under the horizontal cutoff line forming pattern Pa and on both sides in the horizontal direction.

On the other hand, the image of the second light
5 source 26 is formed as an inverted image on the virtual
vertical screen by the light reflected from the second
reflector 28. If the reflecting surface 28a is a paraboloid
of revolution, images Id, Ie and If of the second light
source 26 formed by the lights reflected from the
10 reflecting regions Zd, Ze and Zf have shapes obtained by
rotating, by 180 degrees, the shape of the light emitting
chip 22 shown in the solid line of Fig. 4(b) in an
inclination state of about 15 degrees, as shown in Fig. 6.

15 In other words, the image Id formed by the light
reflected from the reflecting region Zd becomes
substantially rectangular, and the images Ie and If formed
by the lights reflected from the reflecting regions Ze and
Zf become substantially trapezoidal. In that case, the
20 image Te formed by the light reflected from the reflecting
region Ze is smaller than the image If formed by the light
reflected from the reflecting region Zf depending on a
difference in a distance from the light emitting chip 22 to
each of the reflecting regions Zd, Ze and Zf.

25 The images Id, Ie and If of the second light source 26
are formed as the oblique cutoff line forming pattern Pd
and the oblique cutoff line reinforcing patterns Pe and Pf
by the deflecting and diffusing functions of the reflecting
30 units 28s formed on the reflecting surface 28a of the
second reflector 28.

In that case, the oblique cutoff line forming pattern
Pd is formed by downward deflecting the image Id of the
35 reflecting region Zd to a position in which an upper edge
thereof is on the level with the oblique cutoff line CL2
and carrying out deflection and diffusion in a direction

which is inclined by about 15 degrees with respect to a horizontal direction. At this time, the image Id takes a substantially rectangular shape and the upper edge thereof is extended in a direction which is inclined by approximately 15 degrees with respect to the horizontal direction. Also in the oblique cutoff line forming pattern Pd, therefore, the upper edge has a high contrast ratio. Consequently, it is possible to obtain the clear oblique cutoff line CL2.

10

Moreover, the oblique cutoff line reinforcing patterns Be and Pf are formed by downward deflecting the images le and If of the reflecting regions Ze and Zf to a position in which they are hidden under the oblique cutoff line CL2 and carrying out deflection and diffusion in a direction which is inclined by about 15 degrees with respect to the horizontal direction. At this time, the images Ie and If take substantially shapes and have upper edges extended in a different direction from the oblique cutoff line CL2. In the oblique cutoff line reinforcing patterns Pe and Pf, the upper edges do not have high contrast ratios. Since the patterns Pe and Pf are hidden under the oblique cutoff line CL2, however, glare generation can be prevented. By the oblique cutoff line reinforcing patterns Pe and Pf, it is possible to maintain a brightness under the oblique cutoff line forming pattern Pd and on both sides in the oblique direction.

As described above, the headlamp 10 for a vehicle according to the exemplary, non-limiting embodiment is constituted to form a light distribution pattern having the horizontal cutoff line CL1 by the first reflecting optical system 20 comprising the first light source 16 including the light emitting diode in which the rectangular light emitting chip 22 is covered with the hemispherical mold lens 24 and the first reflector 18 for reflecting a light emitted from the first light source 16 toward the front

part of the lighting unit. The first light source 16 is provided such that the light emitting chip 22 is turned in the horizontal direction with one side of the light emitting chip 22 set almost horizontally, and furthermore, 5 the first reflecting optical system 20 is constituted to form the horizontal cutoff line CL1 by selectively utilizing a light emitted from the first light source 16 and reflected by the first reflector 18 which is reflected in the reflecting region Za positioned in the almost front 10 direction of the light emitting chip 22. Therefore, at least the following functions and advantages can be obtained.

The present invention has various advantages. For 15 example, but not by way of limitation, the light emitting chip 22 of the first light source 16 is formed rectangularly and turned in the horizontal direction with the side set horizontally. Therefore, the inverted image of the first light source 16 formed on the virtual vertical 20 screen provided in the forward part of the lighting unit by the light reflected in the reflecting region Za positioned in the almost front direction of the light emitting chip 22 becomes the almost rectangular image Ia having an upper edge extended almost horizontally. In the exemplary, 25 non-limiting embodiment, the almost rectangular image Ta is utilized to form the horizontal cutoff line forming pattern Pa. Consequently, it is possible to obtain the clear horizontal cutoff line CL1. Thus, the generation of glare can be suppressed effectively.

30

In the embodiment, a light distribution pattern having the oblique cutoff line CL2 rising obliquely from the horizontal cutoff line CL1 at about 15 degrees is formed by the second reflecting optical system 30 comprising the 35 second light source 26 including the light emitting diode in which the rectangular light emitting chip 22 is covered with the hemispherical mold lens 24 and the second

reflector 28 for reflecting a light emitted from the second light source 26 toward the front part of the lighting unit. In that case, the second light source 26 is provided such that the light emitting chip 22 is turned in a direction which is downward inclined at about 15 degrees with respect to the horizontal direction with one side of the light emitting chip 22 set horizontally. Furthermore, the second reflecting optical system 30 forms the oblique cutoff line CL2 by selectively utilizing a light emitted from the second light source 26 and reflected by the second reflector 28 which is reflected in the reflecting region Zd positioned in the almost front direction of the light emitting chip 22. Therefore, the following functions and advantages can be obtained.

More specifically, the light emitting chip 22 of the second light source 26 is formed rectangularly and is turned in the direction which is downward inclined at about 15 degrees with respect to the horizontal direction with the side set horizontally. Therefore, the inverted image of the second light source 26 which is formed on the virtual vertical screen provided in the forward part of the lighting unit by the light reflected in the reflecting region Zd positioned in the almost front direction of the light emitting chip 22 becomes the almost rectangular image Id having an upper edge rising obliquely at about 15 degrees with respect to the horizontal direction. In the embodiment, the almost rectangular image Id is utilized to form the oblique cutoff line forming pattern Pd. Consequently, it is possible to obtain the clear oblique cutoff line CL2. Thus, the distant visibility of a self-car driver can be maintained, and furthermore, the generation of glare can be suppressed effectively.

In the embodiment, furthermore, the first reflector 18 and the second reflector 28 are formed integrally. Therefore, the positional relationship between the

horizontal cutoff line CL1 and the oblique cutoff line CL2 can be decided. Moreover, the aiming regulation of the headlamp 10 for a vehicle can be collectively carried out for both of the first and second reflecting optical systems
5 20 and 30.

In the exemplary, non-limiting embodiment, when the horizontal cutoff line forming pattern Pa and the oblique cutoff line forming pattern Pd are formed, the image Ia of
10 the reflecting region Za and the image Id of the reflecting region Zd are deflected downward to the position in which the upper edges thereof are level with the horizontal cutoff line CL1 and the oblique cutoff line CL2. The optical axes Ax1 and Ax2 may be previously set downward
15 corresponding to the downward deflection. In such a case, the concavo-convex amount of each of the reflecting units 18s and 28s can be reduced. Consequently, it is possible to easily form the reflecting surfaces 18a and 28a.

20 While the lights emitted from the first and second light sources 16 and 26 which are reflected by the first and second reflectors 18 and 28 are subjected to deflecting and diffusing control by the reflecting units 18s and 28s formed on the reflecting surfaces 18a and 28a in the
25 embodiment, it is also possible to employ a structure in which a plurality of lens units is formed on the transparent cover 14 and the deflecting and diffusing control is carried out by refraction.

30 While the headlamp 10 for a vehicle comprises one first reflecting optical system 20 and one second reflecting optical system 30 in the embodiment, it is also possible to employ a structure in which the first and second reflecting optical systems 20 and 30 are provided in
35 plural sets. In such a case, the light distribution pattern PL for a low beam can have a higher brightness.

CLAIMS

1. A headlamp for a vehicle, said headlamp having a first light distribution pattern having a horizontal cutoff line
5 formed by a first reflecting optical system, comprising:

a first light source including,

a first semiconductor light emitting unit in which a
10 substantially rectangular first light emitting chip is covered by a substantially hemispherical first mold lens, and

a first reflector reflecting light emitted from the first
15 light source toward a front part of a lighting unit, wherein the first light source is oriented such that the

first light emitting chip is positioned substantially horizontally with a side of the light emitting chip that is
20 set substantially horizontally, and

the first reflecting optical system forms the horizontal
cutoff line by selectively utilizing the light emitted from
25 the first light source and reflected by the first reflector in a first reflecting region positioned in a substantially front direction of the light emitting chip.

2. The headlamp according to claim 1, said headlamp
30 having a second light distribution pattern having an oblique cutoff line rising from the horizontal cutoff line at an angle by a second reflecting optical system, comprising:

35 a second light source including,

a second semiconductor light emitting unit in which a substantially rectangular second light emitting chip is covered with a second substantially hemispherical mold lens, and

5

a second reflector reflecting light emitted from the second light source toward a front part of said lighting unit, wherein the second light source is oriented such that the

10 second light emitting chip is inclined downward at said angle with respect to a horizontal direction with a side of the second light emitting chip that is set substantially horizontally, and

15 the second reflecting optical system forms the oblique cutoff line by selectively utilizing light emitted from the second light source and reflected by the second reflector in a second reflecting region positioned in a substantially front direction of the light emitting chip.

20

3. The headlamp according to claim 2, wherein the first reflector and the second reflector are formed integrally with one another.

25 4. The headlamp according to claim 3, wherein said first reflector and said second reflector are integrally formed on a common holder positioned therebetween.

30 5. The headlamp according to claim 2, 3 or 4 wherein said angle is about 15 degrees.

6. The headlamp according to any one of the preceding claims 1, wherein said first and/or second light reflecting region corresponds to an angular range of about 50 degrees
35 with respect to a central axis of light emitted by the first semiconductor light emitting unit.

7. The headlamp according to any one of the preceding claims, wherein said first and/or second reflector further comprises inner and outer peripheral sides that receive light generated at a peripheral region of the first light emitting chip.

8. The headlamp according to claim 7, wherein the peripheral region corresponds to an area outside an angular range of 50 degrees with respect to a central axis of light emitted by the first semiconductor light emitting unit.

9. A headlamp having a light distribution pattern having a horizontal cutoff line and an oblique cutoff line rising from the horizontal cutoff line at an angle, formed by a reflecting optical system that comprises:

a first light source having a first semiconductor light emitting unit including a first light emitting chip covered by a first mold lens;

a first reflector reflecting light emitted from the first light source toward a front of a lighting unit;

a second light source having a second semiconductor light emitting unit including a second light emitting chip covered with a second mold lens; and

a second reflector reflecting light emitted from the second light source toward a front of said lighting unit,

wherein the first light emitting chip is positioned substantially horizontally with a side of the light emitting chip, which is set substantially horizontally,

the second light emitting chip is inclined downward at said angle with respect to said horizontally positioned first light emitting chip, the horizontal cutoff line is formed

by selectively utilizing the light emitted from the first light source and reflected by the first reflector in a first reflecting region positioned in front of the light emitting chip, and

5

the oblique cutoff line is formed by selectively utilizing the light emitted from the second light source and reflected by the second reflector in a second reflecting region positioned in front of the light emitting chip.

10

10. The headlamp according to claim 9, wherein the first reflector and the second reflector are formed integrally with one another.

15

11. A headlamp having a light distribution pattern having a horizontal cutoff line and an oblique cutoff line rising from the horizontal cutoff line at an angle, formed by a reflecting optical system that comprises:

20

means for generating a first light output and a second light output; and

means for reflecting said first light output and said second light output from said means for generating toward a front of a lighting unit to produce said horizontal cutoff line and said oblique cutoff line, respectively.

25

12. A headlamp substantially as described with reference to the accompanying drawings.

30



INVESTOR IN PEOPLE

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Application No: GB0404787.4

Examiner: Gareth Bond

Claims searched: 1 to 10

Date of search: 26 July 2004

Patents Act 1977: Search Report under Section 17

Documents considered to be relevant:

Category	Relevant to claims	Identity of document and passage or figure of particular reference
X,E	1, 7	EP1418629 A2 (Koito Manufacturing) See figures 13 to 17 and paragraphs 7, 73, 74, 77, 78, 86 to 90 and 92.
A,E	-	GB2394036 A (Koito Manufacturing) See whole document particularly figures 2 and 3.
A,P	-	EP1357333 A2 (Koito Manufacturing) See whole document.
A	-	US2003/0035299 A1 (Koito Manufacturing) See whole document

Categories:

X	Document indicating lack of novelty or inventive step	A	Document indicating technological background and/or state of the art.
Y	Document indicating lack of inventive step if combined with one or more other documents of same category.	P	Document published on or after the declared priority date but before the filing date of this invention.
&	Member of the same patent family	E	Patent document published on or after, but with priority date earlier than, the filing date of this application.

Field of Search:

Search of GB, EP, WO & US patent documents classified in the following areas of the UKC^W :

F4R

Worldwide search of patent documents classified in the following areas of the IPC⁰⁷

B60Q; F21H; F21S; F21V

The following online and other databases have been used in the preparation of this search report

WPI, EPODOC, PAJ;